Structural Defects

Switching on the Photocatalysis of Metal–Organic Frameworks by Engineering Structural Defects

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Abstract: Defect engineering is a versatile approach to modulate band and electronic structures as well as materials performance. Herein, metal–organic frameworks (MOFs) featuring controlled structural defects, namely UiO-66-NH₂-X (X represents the molar equivalents of the modulator, acetic acid, with respect to the linker in synthesis), were synthesized to systematically investigate the effect of structural defects on photocatalytic properties. Remarkably, structural defects in MOFs are able to switch on the photocatalysis. The photocatalytic H₂ production rate presents a volcano-type trend with increasing structural defects, where Pt@UiO-66-NH₂-100 exhibits the highest activity. Ultrafast transient absorption spectroscopy unveils that UiO-66-NH₂-100 with moderate structural defects possesses the fastest relaxation kinetics and the highest charge separation efficiency, while excessive defects retard the relaxation and reduce charge separation efficiency.

Defects, disruptions of the periodic atomic arrangements in the crystal lattice, are almost universal in the structure of solid materials, despite the great efforts made to achieve minimum-energy systems.[1] The formation of structural defects is generally accompanied by bond breaking and reforming, lattice distortion, and electron localization, which induce property changes in various applications. For instance, short-range disordered structural defects can behave as scattering centers by breaking electronic structure and causing localized band-tail states, thus affecting the mobility and conductivity.[1] Therefore, defects have long been regarded as unfavorable imperfections that can deteriorate the performance of materials.[2] In contrast, in-depth experimental and theoretical studies recently revealed the importance of defects in tailoring the local properties of solid materials and endowing them with new functionalities and/or enhanced performances.[3] Particularly, the control of lattice defects in semiconductive materials may be able to modulate the electronic and band structures, carrier concentration, and even the conductivity.[3] Moreover, from the perspective of surface science and catalysis, the coordinatively unsaturated sites associated with surface defects can serve as active sites for molecular absorption and activation.[4] Therefore, the rational creation of structural defects may offer the opportunity to tune and optimize the performance. Given the subtle influence of defects on properties, especially catalysis, it is of great importance to employ a suitable model and rationally engineer structural defects for a deeper understanding of the relationship between defect control and performance.

Metal–organic frameworks (MOFs), a class of crystalline porous material, are assembled from inorganic metal ions/clusters and organic linkers.[5] The periodic and well-defined structures of MOFs make them ideal candidates for defect studies. Starting from perfect single-crystal structures, the rational introduction of structural defects into MOFs is feasible by regulating the synthetic parameters that may affect the properties. Owing to the unique advantages of MOFs, including high surface area, well-exposed active sites, and free transport of substrates/products in the pores, there have been intensive explorations toward catalysis and photocatalysis based on their structural modulation and decoration in recent years.[6] Although a few recent investigations on MOF defects have suggested preliminary influences on catalysis and sorption,[7] to the best of our knowledge, there has never been experimental exploration to clarify how different levels of structural defects in MOFs systematically affect the photocatalytic performance.

As a representative MOF, UiO-66-NH₂[8] was chosen for this study due to its facile synthesis, great stability, structural tailorability, and high tolerance for structural modulation.[7] Previous theoretical studies have indicated that the removal of linkers in UiO-66 lowers energy levels of the unoccupied d orbitals of Zr atoms, which may increase the likelihood of charge transfer in the photocatalytic process.[9] In this context, with controlled defect engineering, UiO-66-NH₂ may be an ideal platform to systematically investigate the relationship between structural defects (level) and photocatalytic performance.

Bearing these considerations in mind, we have rationally synthesized UiO-66-NH₂ with different contents of structural defects, denoted as UiO-66-NH₂-X (where X = 0, 50, 100, 150, 200, representing the molar equivalents of the modulator with respect to the linker upon synthesis), for photocatalytic H₂
production, in the presence of Pt nanoparticles (NPs) as cocatalyst (Scheme 1). Along with the increase in structural defects, the photocatalytic H₂ production rate gradually increases. However, unlike previous reports,⁶⁻⁹ the photocatalytic activity gradually decreases with further increases in defect contents (X = 150, 200). Therefore, the activity of Pt@UiO-66-NH₂-X presents an evident volcano-type trend, with the highest point at X = 100. Resorting to femtosecond time-resolved transient absorption spectroscopy, the relationship between charge separation efficiency and defect levels of UiO-66-NH₂-X has been studied to understand this volcano-type trend in the photocatalytic behavior. As far as we know, this is the first experimental demonstration on the different roles of MOF defects in photocatalysis, highlighting the importance of moderate structural defects.

UiO-66-NH₂-X with different structural defect contents were prepared by the reaction of ZrCl₄ and 2-amino-1,4-benzenedicarboxylic acid (NH₂-BDC) in N,N-dimethylformamide, with trace amounts of water and different equivalents of acetic acid (HOAc) as modulator; the working principle of the modulator in defect formation was illustrated in detail (see the Supporting Information, Section 6). All UiO-66-NH₂-X MOFs (X = 0, 50, 100, 150, 200) show similar powder X-ray diffraction (XRD) patterns, suggesting their good crystallinity (Figure 1a). Scanning electron microscopy (SEM) observation indicates that the MOF particles gradually change from small and intergrown prototypes to individual and octahedral nanocrystals, along with increasing particle sizes until X = 100 (Figure S1).

Several techniques have been adopted to investigate the degree of structural defects in UiO-66-NH₂-X. First, thermogravimetric analysis (TGA) curves of five UiO-66-NH₂-X are qualitatively similar and present two well-resolved weight loss steps (Figure 1b). The weight loss in the range of 25–320°C mainly corresponds to the loss of H₂O adsorbate and HOAc modulator. As the temperature increases up to 500°C, the NH₂-BDC linker fully combuts with complete collapse of the framework, as verified by the intense exothermic peak in the differential thermal analysis (DTA) curves. The final residue can be mainly assigned to the monoclinic ZrO₂ with some cubic ZrO₂ (Figure S2); this is normalized to 100% for all samples to facilitate comparison (Figure 1b). Notably, the last weight loss step can be applied to compare the defect degree in different samples.⁷⁻¹⁰ The magnitude of weight loss in the last step corresponding to linker/framework combustion gradually decreases from UiO-66-NH₂-0 to UiO-66-NH₂-200 (Figure 1b), indicating that the linker content in MOFs gradually decreases and more defects exist, exactly as expected. Therefore, it can be established that the amount of modulator in the synthetic process is inversely correlated to the amount of weight loss, while it is positively correlated to the defect degree in UiO-66-NH₂-X.

We then resorted to the dissolution/¹H NMR analysis, an effective tool to identify the ratio of the NH₂-BDC linker and the HOAc modulator coordinated to the Zr-oxo clusters (Figure 1c).⁷⁻¹⁰ A significant signal enhancement assignable to CH₂COO⁻ can be observed in the ¹H NMR spectra of digested UiO-66-NH₂-X with gradually increasing X values, suggesting the incremental replacement of the linker by the HOAc modulator. Intuitively, when the dicarboxylate linker is replaced by an end-capped monocarboxylate modulator, additional pore space would be created in the MOF, which leads to higher surface area and affects the properties of UiO-66-NH₂-X.⁷ Not surprisingly, N₂ uptake gradually increases for UiO-66-NH₂-X synthesized with a higher ratio of HOAc (Figure 1d). Consequently, the Brunauer–Emmett–Teller (BET) surface area of the MOFs increases from 705 to 1057 m² g⁻¹ and the pore volume increases from 0.53 to 0.62 cm³ g⁻¹, for UiO-66-NH₂-X with increased X and more defects (Table S1), while the pore size distribution does not change significantly (Figure S3). Notably, the influence of structural defects on the stability of UiO-66-NH₂ has been
demonstrated to be negligible (Figures S4–S6). Moreover, the type of structural defects in UiO-66-NH2-X is believed to be the missing linkers, according to our reaction conditions and previous reports.[7e,k,9b]

The UV/Vis spectra of all UiO-66-NH2-X MOFs show similar curves in the range 250–800 nm (Figures S7–S11), and the calculated band gap for all MOFs is ≈ 3.0 eV (Table S2). The results indicate that the light-harvesting ability of these UiO-66-NH2-X MOFs with a slight change in color (Figure S12) is hardly influenced by structural defects or particle size.[9a]

To boost the transfer and utilization of charge carriers in UiO-66-NH2-X for photocatalysis, ≈ 1 wt % Pt NPs as co-catalyst was incorporated into the MOFs to afford Pt@UiO-66-NH2-X composites (Table S3). This was done by adding UiO-66-NH2-X to the Pt precursor solution, followed by reduction at 200 °C in an H2/Ar atmosphere.[10] Powder XRD patterns suggest that the introduction of Pt NPs does not affect the crystallinity of UiO-66-NH2-X (Figure S13). Transmission electron microscopy (TEM) observation indicates that Pt NPs with an average size of 1.2–1.4 nm are dispersed evenly in UiO-66-NH2-X particles (Figure 2a,b, Figures S14–S18).

Next, we set out to investigate the photocatalytic H2 production over Pt@UiO-66-NH2-X with triethanolamine (TEOA) as a sacrificial agent. Pt@UiO-66-NH2-0, in which the MOF features few structural defects, was synthesized without modulator and presents negligible H2 production (9.4 μmol g−1 h−1). The very poor activity of Pt@UiO-66-NH2-0 may be attributed to the lack of overlap between the empty d orbitals of Zr4+ and the π* orbital of the linker and the obstruction of electron transfer from the linker to Zr4+[6f,9a] in UiO-66-NH2-X MOFs having more structural defects, Pt@UiO-66-NH2-50 and Pt@UiO-66-NH2-100, exhibit much enhanced H2 production rates of 154.2 and 381.2 μmol g−1 h−1, respectively, suggesting that structural defects play a critical role in photocatalysis. However, the photocatalytic activity of Pt@UiO-66-NH2-150 and Pt@UiO-66-NH2-200, with further incremental structural defects, drops to 302.1 and 276.8 μmol g−1 h−1, respectively. Therefore, the photocatalytic activity shows a volcano-type trend on the whole, and Pt@UiO-66-NH2-100 presents the highest activity among all the investigated photocatalysts (Figure 2c, Figure S19a). Moreover, Pt@UiO-66-NH2-100 is well recyclable for at least 10 cycles (Figure 2d, Figure S19b), and its structure can be well retained, without any noticeable leaching or aggregation occurred to Pt NPs, after photocatalytic cycles (Figures S20 and S21). The impressive volcano-type trend explicitly shows that, though a suitable content of structural defects is favorable, too high concentration is detrimental to the activity. In addition, as a preliminary demonstration, the tandem reaction of photocatalytic H2 production and nitro-benzene hydrogenation over Pt@UiO-66-NH2-100 can be promoted in the absence of an additional hydrogen source (Figure S22).

To better understand the mechanism behind the observed volcano-type trend in activity, we resorted to femtosecond time-resolved transient absorption (fs-TA) spectroscopy to examine the charge separation processes involved.[11] In the fs-TA measurements with a pump–probe configuration, the pump was set at 400 nm, a wavelength suitable for promoting electrons from the highest occupied molecular orbital (HOMO) to the lowest unoccupied molecular orbital (LUMO) of UiO-66-NH2 whereas the probe was from a white-light-continuum source covering a spectral region of 500–700 nm. Representative fs-TA spectra recorded for UiO-66-NH2-0 and UiO-66-NH2-100 show that different levels of structural defects bring on no essential variation in the spectral profile (Figure 3a). However, pronounced changes can be detected in their kinetic behavior (Figure 3b). Considering that relaxation kinetics usually depends on the probing wavelength, we conducted a global fit to retrieve the relaxation constants, in which a set of kinetic traces ranging from 580 to 650 nm with a 10 nm interval were used. The fitting results are as follows: τ1 = 81 ± 2 ps (54%) and τ2 = 689 ± 24 ps (46%) for UiO-66-NH2-0; τ1 = 67 ± 2 ps (55%) and τ2 = 617 ± 23 ps (45%) for UiO-66-NH2-50; τ1 = 20 ± 1 ps (29%) and τ2 = 384 ± 5 ps (71%) for UiO-66-NH2-100; τ1 = 174 ± 5 ps (61%) and τ2 = 1062 ± 59 ps (39%) for UiO-66-NH2-150; and τ1 = 218 ± 6 ps (70%) and τ2 = 1492 ± 113 ps (30%) for UiO-66-NH2-200. The average relaxation lifetimes are 615 ± 22, 553 ± 21, 376 ± 5, 881 ± 53, and 1167 ± 101 ps for UiO-66-NH2-X (X = 0, 50, 100, 150, 200, respectively), as also annotated in Figure 3b. As compared in Figure 3c, the variation of such a set of average relaxation lifetimes presents an exactly inverse relation to the observed volcano-type trend of H2 production rates at different defect levels (X = 0–100; 100–200). The average relaxation lifetime can be employed as an indicator to evaluate charge separation efficiency: the faster

![Figure 2. Typical TEM images of a) Pt@UiO-66-NH2-0 and b) Pt@UiO-66-NH2-100, c) photocatalytic H2 performance from water splitting over different catalysts in MeCN/TEOA/H2O (10:8:1:0.2 v/v, 30 mL) under light irradiation, d) recycling performance of Pt@UiO-66-NH2-100 (2 h per cycle).](image-url)
the relaxation, the higher the efficiency. The fastest relaxation observed in UiO-66-NH$_2$-100 is synchronous with the most predominant H$_2$ production rate of Pt@UiO-66-NH$_2$-100, indicating that UiO-66-NH$_2$-100 with a moderate defect level achieves the highest charge separation efficiency. It is worth noting that the average relaxation lifetimes of UiO-66-NH$_2$-X (X = 0, 50) are longer than those of UiO-66-NH$_2$-X (X = 150, 200), again indicating that the too high defect density in UiO-66-NH$_2$-X (X = 150, 200) is not beneficial for promoting electron–hole separation efficiency.

Transient photocurrent measurements and electrochemical impedance spectroscopy (EIS) were conducted to further verify the volcano-type trend in the activity of Pt@UiO-66-NH$_2$-X photocatalysts. As expected, Pt@UiO-66-NH$_2$-100 presents the highest photocurrent response among all the samples (Figure 4a), implying that the creation of the optimal level of structural defects is vital to the efficient separation of photogenerated charge, while excessive structural defects, conversely, can turn into recombination centers of electron–hole pairs, thus causing reduced activity.

In summary, we selected UiO-66-NH$_2$ as a model for the systematical investigation of the specific influence of structural defects on photocatalysis. The photocatalytic H$_2$ production presents an interesting volcano-type trend along with incremental levels of structural defects in the MOF. Impressively, Pt@UiO-66-NH$_2$-100, with an optimized content of structural defects, possesses the highest photocatalytic activity, highlighting that the creation of moderate structural defects is vital to promoting the efficient electron–hole separation. Remarkably, the significant distinction of charge separation efficiency caused by different defect levels has been systematically evidenced by fs-TA spectroscopy in terms of relaxation kinetics. Taken together, these results unambiguously demonstrate that the creation of structural defects can switch on photocatalysis and its content optimization is critical to photocatalytic performance. This work provides significant inspiration for the creation of structural defects in functional materials to optimize performance, particularly in semiconductor(-like) materials for enhanced photocatalysis.

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Conflict of interest

The authors declare no conflict of interest.

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